Physisorption of hydrogen on graphene

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Outline

1. Context

2. Model

H-graphene/graphite interaction potentialPhonon modelThe specific problem of grapheneH-phonon coupling modelDynamical methods

3. Physisorption of H on graphene Comparison RDM-CCWP Resonance processes Effect of the phonon model Effect of the number of layers (graphite)

Context : graphene

High sensitivity low Temperature Nano Electro Mechanical Systems (NEMS)



Actuation : Oscillating electrostatic force induced by gate DC+AC voltage →Mechanical oscillations of graphene (resonator).

Detection : current variation induced by vibration-dependant conductance.

Resonance : improvement of quality factor at low T

Mass detection : zepto-gramme (10-21 g) sensitivity $f = \sqrt{\frac{k}{m}}$

Sticking properties central

B. Lassagne, A. Bachtold / C. R. Physique 11 (2010) 355-361

Hydrogenation of graphene : what about physisorption ?

Control of Graphene's Properties by Reversible Hydrogenation: Evidence for Graphane

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Although graphite is known as one of the most chemically inert materials, we have found that graphene, a single atomic plane of graphite, can react with atomic hydrogen, which transforms this highly conductive zero-overlap semimetal into an insulator. Transmission electron microscopy

30 JANUARY 2009 VOL 323 SCIENCE

Graphene exposed to low pressure (0.1 mbar) H2 (10%)-Ar for 2 hours



H-graphite/graphene interaction

V(z) (meV)



Sha, Jackson, 2002

DISSIPATIVE MECHANISMS NECESSARY FOR STICKING :

- electron-hole excitation ?

⁻ phonon excitation ?

GRAPHENE/GRAPHITE STRUCTURE



ELECTRONIC STRUCTURE OF GRAPHENE

sp2 hybridization : 1s2 2s2 2p2 # 1s2 $\sigma3\,\pi$

Network of conjugated π bonds \ast conductivity





BAND STRUCTURE





DENSITY OF STATES

t=2.8 eV

REVIEWS OF MODERN PHYSICS, VOLUME 81, JANUARY-MARCH 2009

The electronic properties of graphene

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Graphene is a semi-metal :

no band gap but 0 density of states at Fermi level

Because of the low density of states near Fermi level, electron-hole formation should not be efficient at low energy

Its efficiency may increase with increasing energy

The model : H-graphite interaction



The model : phonons



The model : phonons

For flexural modes (perpendicular to the surface)

Intra-layer :

Valence-force-field with 2 « spring constants » : out-of-plane bending+twisting

T. Aizawa, R. Souda, S. Otani, Y. Ishizawa, C. Oshima, Phys. Rev. B 42 (1990) 11469

Inter-layer :

1 nearest-neighbor « spring constant » R. Nicklow, N. Wakabayashi, H.G. Smith, Phys. Rev. B 5 (1972) 4951





The model : phonons



D = 2 : graphene, D = 3 : graphite



$$u_{i} = \frac{1}{(MN)^{\frac{1}{2}}} \sum_{\mathcal{Q}\sigma} U_{\mathcal{Q}\sigma} \varepsilon_{\mathcal{Q}\sigma}^{s_{i}} e^{i\mathcal{Q}(l_{i}+s_{i})}$$

Thermal average :
$$n_{\omega}(T) = \frac{1}{e^{\frac{\hbar\omega}{kT}} - 1}$$

Correlation between displacements at different point = measure of long range order :

$$\langle (u_i - u_j)^2 \rangle = \frac{\hbar}{MN} \sum_{Q\sigma} \frac{1}{\omega_{Q\sigma}} \left(n_{Q\sigma} (T) + \frac{1}{2} \right) \left| \varepsilon_{Q\sigma}^{s_i} \right|^2 \left(1 - \cos(Q(r_i - r_j))) \right| \rightarrow \frac{kT}{M} \int d\omega \rho (\omega) \left(\frac{Q}{\omega} \right)^2$$

R. Peierls, *Quelques propriétés typiques des corps solides* Annales de l'IHP, 5 (1935) 177

- Stabilization role of coupling between bending and stretching (anharmonicity)
- Stabilization role of substrate ?
- Even for suspended graphene ?

The structure of suspended graphene sheets

Jannik C. Meyer¹, A. K. Geim², M. I. Katsnelson³, K. S. Novoselov², T. J. Booth² & S. Roth¹ NATURE Vol 446 1 March 2007

Integrand	LA, TA	ZA
GRAPHITE	ω2	$\omega \theta$
GRAPHENE	$\omega 0$	<i>ω-1</i>



GRAPHENE : PHONON PROBLEM

Interaction with substrate for supported graphene

· Weak and not well known vdw interaction

• Graphite :

interlayer distance : 3.4 Å interlayer energy : 20 meV/Å2 = 50 meV/atom

 Graphene supported on SiO2 : SiO2-graphene distance : h0= 4.2 Å SiO2-graphene interaction energy Γ0≈ 6 meV/Å2 = 0.1 J/m2

· Force constant for vibration of graphene on SiO2

 $U_{vdW}(h) = -\Gamma_0 \left[\frac{3}{2} \left(\frac{h_0}{h} \right)^3 - \frac{1}{2} \left(\frac{h_0}{h} \right)^9 \right]$

$$KZA = 2 d2UvdW/dh2 = 27Sa \ \Gamma O /hO \approx 0.8 \ N/m$$



GRAPHENE : PHONON PROBLEM

Interaction with substrate for supported graphene



- · Shift of the dispersion curve
- singularity integrable (van Hove)
- * stabilization



GRAPHENE : PHONON PROBLEM

Self tension for suspended graphene



Measurement of the Elastic **Properties and Intrinsic Strength** of Monolayer Graphene

Changgu Lee,^{1,2} Xiaoding Wei,¹ Jeffrey W. Kysar,^{1,3} James Ho

SCIENCE VOL 321 18 JULY 2008

- Due to the attraction of the SiO2 substrate (vdw interaction $\approx 0.1 \text{ J/m2} = 16 \text{ meV/atom}$)
- Generates a dip z0 \approx 2-20 nm
- Stabilizes graphene and reduces corrugation
- · Self tension $\sigma \approx 0.1$ -1 N/m (from *F*/ Δz)
- Strain < 1% ($\approx \sigma/E2D$, $E2D=E^*(c/2)$, $E\approx 1$ TPa)



Impermeable Atomic Membranes from **Graphene Sheets**

J. Scott Bunch, Scott S. Verbridge, Jonathan S. Alden, Arend M. van der Zande, Jeevak M. Parpia, Harold G. Craighead, and Paul L. McEuen*

NANO LETTERS

2008 Vol. 8, No. 8 2458-2462

Propagation of self tension

At equilibrium:

3 identical forces F /atom

 σ =12 *F*/perimeter * *F*/a

(for a large number of crowns)

This constant force F is added to the lattice dynamics model





 \cdot 0 DOS at \varGamma point

- removal of the singularity
- \ast stabilization



Conclusions on graphene stability and role of substrate

1. As it is a 2D membrane, graphene has an anomalous acoustic phonon dispersion

2. This anomalous dispersion induces thermal instabilities

3. Stability as a flat membrane is restored by the presence of the substrate :

- supported graphene : direct force between substrate and membrane
- suspended graphene : tension induced by the surrounding attractive substrate contributes to stability

The model : Phonons

Models considered

$$C_{eff} = \sum_{\mathbf{Q}} \frac{n(\omega_{\mathbf{Q}})e_z(\omega_{\mathbf{Q}})^2}{\omega_{\mathbf{Q}}} \dots \propto \int d\omega \eta(\omega) \frac{n(\omega)e_z(\omega)^2}{\omega}.$$

Lattice dynamics
1-3-5-10 layers

- 1-3-5-10 layers

With or without n+1 layer fixed Integrand of $Ceff \approx \omega - 1$ (free-standing) or $\omega 0$ (on-

substrate)

→strong coupling

$$\omega_{\mathbf{Q}} = \omega_{max} \sin\left(\frac{\pi Q}{2Q_{max}}\right) \quad e_Z(\mathbf{Q}) = \left(\sin\left(\frac{\pi Q}{2Q_{max}}\right)\right)^{\frac{1}{2}} \mathbf{C}$$

Integrand of $Ceff \approx \omega l$ * milder coupling

The model : H-phonons interaction

Linear coupling approximation :

$$V_{c}(\mathbf{r}, \{\mathbf{u}_{\mathbf{i}}\}) = 2\alpha\Delta(z)\sum_{i} \frac{\partial W(\mathbf{R}, \{\mathbf{u}_{\mathbf{i}}\})}{\partial \mathbf{u}_{\mathbf{i}}} \mathbf{u}_{\mathbf{i}} \qquad \frac{\partial W(\mathbf{R}, \mathbf{0})}{\partial \mathbf{u}_{\mathbf{i}}} = Ae^{-\frac{1}{2}Q_{c}^{2}(\mathbf{R}-\mathbf{R}_{\mathbf{i}})^{2}}$$

Bortolani, Franchini, Garcia, Nizzoli,

Santoro, Phys. Rev. B 28, 7358 (1983)

Expansion on phonon modes :

$$V_c(\mathbf{r}, \{\mathbf{u_i}\}) = 2\alpha A\Delta(z) \frac{2\pi}{A_{uc} N_p^{\frac{1}{2}} Q_c^2} \sum_{\mathbf{Q}} \left(\frac{\hbar}{2M\omega_{\mathbf{Q}}}\right)^{\frac{1}{2}} e^{i\mathbf{Q}\mathbf{R}} \ e^{-\frac{1}{2}\frac{\mathbf{Q}^2}{Q_c^2}} e_Z(\mathbf{Q}) \left(a_{\mathbf{Q}} + a_{-\mathbf{Q}}^{\dagger}\right)$$



 $\eta(\omega)$: density of phonon states $\eta(\omega=0)$ crucial

The model : Dynamical methods



Close coupling wave packet (CCWP) :

$$\psi(\mathbf{r},t) = \sum_{i=1-N_r,\lambda=0,\pm 1,\mathbf{Q}} c_i^{\lambda \mathbf{Q}}(t) e^{-i\lambda \mathbf{QR}} \varphi_i(\mathbf{r}) |\{n\}_{\lambda \mathbf{Q}} >$$

$$i\hbar \frac{dc_i^{\lambda \mathbf{Q}}(t)}{dt} = \left(\epsilon_i + \frac{\hbar^2 \lambda^2 Q^2}{2m} + \lambda \hbar \omega_{\mathbf{Q}}\right) c_i^{\lambda \mathbf{Q}}(t) + \sum_{i',\lambda',\mathbf{Q}'} \frac{\mathsf{Phonon \ coupling}}{V_c^{\lambda \mathbf{Q} i \ \lambda' \mathbf{Q}' i'} c_{i'}^{\lambda' \mathbf{Q}'}(t)$$

Perturbative treatment (PT) : $\lambda=0$ wavepacket not affected by phonons

Results : Comparison of RDM/CCWP







Results : Diffraction mediated selective adsorption



Results : effect of the choice of phonon model



Jackson model

Lattice dynamics model

Strong dependence on phonon model : different density of states and polarisation vectors DMSA resonances effective in both cases

Results : effect of the number of layers



Lattice dynamics model, on substrate



DOS

 Threshold effect for 1 layer : low energy phonons not available to stick to excited vibrational states at low energy

· Convergence for number of layers ≥ 3

Conclusions

- Development of 3D (with corrugation) model for H sticking on graphite including a realistic lattice dynamics model
- 2. Corrugation : strong effect of DMSA resonances on sticking
- B. Phonons : strong influence of the choice of model
- 1. Stabilizing of substrate to have flat graphene
- 5. Future work : chemisorption